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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/633,230	08/04/2003	Tadashi Miwa	241174US2S	2441	
22850	7590 05/27/2005	EXAMINER			
OBLON, SPIVAK, MCCLELLAND, MAIER & NEUSTADT, P.C. 1940 DUKE STREET			HUYNH, ANDY		
ALEXANDRIA, VA 22314			ART UNIT	PAPER NUMBER	
			2818	-	
			DATE MAILED: 05/27/2005		

Please find below and/or attached an Office communication concerning this application or proceeding.

		Amplicati	N-	01:4/->					
Office Action Summary		Applicati	on No.	Applicant(s)					
		10/633,2	30	MIWA, TADASHI					
		Examine	•	Art Unit					
		Andy Huy	nh	2818					
The MAIL Period for Reply	The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply								
THE MAILING D - Extensions of time m after SIX (6) MONTH - If the period for reply - If NO period for reply - Failure to reply within Any reply received by	STATUTORY PERIOD F ATE OF THIS COMMUN ay be available under the provisions S from the mailing date of this com specified above is less than thirty (is is specified above, the maximum s the set or extended period for reply the Office later than three months djustment. See 37 CFR 1.704(b).	IICATION. s of 37 CFR 1.136(a). In no ev munication. 30) days, a reply within the stat tatutory period will apply and w y will, by statute, cause the app	ent, however, may a reply be timutory minimum of thirty (30) days ill expire SIX (6) MONTHS from lication to become ABANDONE	nely filed s will be considered timely. the mailing date of this communication. D (35 U.S.C. § 133).					
Status									
1) Responsiv	e to communication(s) fil	ed on 06 May 2005.							
· ·									
<u>'</u>									
•	ccordance with the pract	•							
Disposition of Clair	ns								
<u> </u>		application							
	Claim(s) <u>1-11</u> is/are pending in the application. 4a) Of the above claim(s) is/are withdrawn from consideration.								
•	Claim(s) is/are allowed.								
<u> </u>	☑ Claim(s)is/are allowed. ☑ Claim(s) 1 is/are rejected.								
·	⊠ Claim(s) <u>2-11</u> is/are objected to.								
	are subject to restri	ction and/or election r	equirement.						
Application Papers									
· ·	cation is objected to by th	ne Evaminer							
· — ·	•		nted or h) Objected:	to by the Examiner					
•	10) The drawing(s) filed on <u>01 August 2003</u> is/are: a) accepted or b) objected to by the Examiner.								
• •	Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a). Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).								
•	11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.								
Priority under 35 U.	S.C. § 119								
· —	gment is made of a claim]Some * c)□ None of:	for foreign priority un	der 35 U.S.C. § 119(a))-(d) or (f).					
1.⊠ Cert									
2.☐ Cert									
3. ☐ Cop	3. Copies of the certified copies of the priority documents have been received in this National Stage								
appl	ication from the Internati	onal Bureau (PCT Ru	e 17.2(a)).						
* See the atta	ched detailed Office action	on for a list of the cert	ified copies not receive	ed.					
Attachment(s)			_						
1) Notice of Reference		DTO 040)	4) Interview Summary						
	son's Patent Drawing Review (ure Statement(s) (PTO-1449 o		Paper No(s)/Mail Da 5) Notice of Informal P	ate Patent Application (PTO-152)					
Paper No(s)/Mail D		· · · - · - · - · · · ·	6) Other:						

DETAILED ACTION

Continued Examination Under 37 CFR 1.114

A request for continued examination under 37 CFR 1.114, including the fee set forth in 37 CFR 1.17(e), was filed in this application after allowance or after an Office action under *Ex Parte Quayle*, 25 USPQ 74, 453 O.G. 213 (Comm'r Pat. 1935). Since this application is eligible for continued examination under 37 CFR 1.114, and the fee set forth in 37 CFR 1.17(e) has been timely paid, prosecution in this application has been reopened pursuant to 37 CFR 1.114. Applicant's submission filed on October 29, 2004 has been entered.

Accordingly, claims 1-11 are currently pending in this application.

Information Disclosure Statement

This office acknowledges receipt of the following items from the applicant: Information Disclosure Statement (IDS) filed 05/06/2005 and made of record as Paper No. 05/06/2005. The references cited on the PTOL 1449 form have been considered.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

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Claim 1 is rejected under 35 U.S.C. 103(a) as being unpatentable over Ichige et al. (JP 2003-051557 hereinafter referred to as "Ichige") in view of Ito et al. (JP 56-137632 hereinafter referred to as "Ito").

Ichige discloses in Figs. 20 and 21 a semiconductor device comprises:

a plurality of first wiring structures 50 of a first width W3 which are arranged periodically at first intervals F;

a second wiring structure 51 which is formed next to one of the first wiring structures and the lower part of which has a second width W4 substantially equal to two times the first width of the first wiring structure.

Ichige fails to teach the lower part of which has a second width substantially equal to the sum of n times the first width of the first wiring structure (n is a positive integer equal to two or more) and (n - 1) times the first interval. Ito teaches in Figs. 1-3 that a patterning technique for forming a pattern width of a second region 14 equal to the sum of a width of n patterns in the first region 10 and the intervals between n-1 patterns in the first region. It would have been obvious to one of ordinary skill in the art at the time of the invention was made to utilize the teaching of a patterning technique for forming a pattern width of a second region equal to the sum of a width of n patterns in the first region and the intervals between n-1 patterns in the first region, as taught by Ito to incorporate into Ichige's structure to arrive the claimed limitations in order to have only the positioning of simple line and space and complicated pattern to be made only once, thus allowing high-yield patterning (see English Abstract).

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Allowable Subject Matter

Claims 2-11 are objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims, since the prior art made of record and considered pertinent to the applicant's disclosure does not teach or suggest the claimed limitations the semiconductor device wherein the upper part of the second wiring structure has n convex parts of substantially the first width and (n-1) concave part as recited in claim 2.

Conclusion

A shortened statutory period for response to this action is set to expire 3 (three) months and 0 (zero) day from the day of this letter. Failure to respond within the period for response will cause the application to become abandoned (see M.P.E.P 710.02(b)).

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Andy Huynh, (571) 272-1781. The examiner can normally be reached on Monday-Friday from 8:30 AM to 5:00 PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, David Nelms can be reached on (571) 272-1787. The Fax number for the organization where this application or proceeding is assigned is (703) 872-9306.

Any inquiry of a general nature or relating to the -status of this application or proceeding should be directed to the receptionist whose phone number is (703) 308-0956.

Information regarding the status of an application may be obtained from the Patent

Application Information Retrieval (PAIR) system. Status information for published applications

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may be obtained from either Private PAIR or Public PAIR. Status information for unpublished

applications is available through Private PAIR only. For more information about the PAIR

system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR

system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Ah

05/19/05

Andy Huynh

Patent Examiner

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